

MOSFET

Metal Oxide Semiconductor Field Effect Transistor

Bare Die

OptiMOS™3 Power MOS Transistor Chip IPC300N15N3R

Data Sheet

Rev. 2.6 Final





IPC300N15N3R

1 **Description**

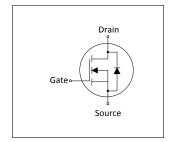
- N-channel enhancement mode
- For dynamic characterization refer to the datasheet of IPP075N15N3 G¹⁾
- AQL 0.65 for visual inspection according to failure catalogue
- Electrostatic Discharge Sensitive Device according to MIL-STD 883C

- Die bond: soldered or glued
 Backside metallization: NiV system
 Frontside metallization: AlCu system
- Passivation: nitride (only on edge structure)



Table 1 Rey 1 chormanee 1 drameters					
Parameter	Value	Unit			
V _{(BR)DSS}	150	V			
R _{DS(on)}	7.5 ²⁾	mΩ			
Die size	6 x 5	mm ²			
Thickness	250	μm			











Type / Ordering Code	Package	Marking	Related Links
IPC300N15N3R	Chip	not defined	-

¹⁾ IPP075N15N3 G dynamic characterization does not include the internal added R_G ²⁾ packaged in a P-TO220-3-1 (see ref. product)





2 Electrical Characteristics on Wafer Level at T_j = 25°C, unless otherwise specified

Table 2

Downwater	Symbol		Values		11	Note / Took Condition
Parameter		Min.	Тур.	Max.	Unit	Note / Test Condition
Drain-source breakdown voltage	V _{(BR)DSS}	150	-	-	V	V _{GS} =0 V ,I _D =1 mA
Gate threshold voltage	$V_{\rm GS(th)}$	2	3	4	V	$V_{\rm DS}$ = $V_{\rm GS}$, $I_{\rm D}$ =250 μ A
Zero gate voltage drain current	I _{DSS}	-	0.1	1	μA	V _{GS} =0 V ,V _{DS} =120 V
Gate-source leakage current	I _{GSS}	-	1	100	nA	V _{GS} =20 V ,V _{DS} =0 V
Drain-source on- resistance	R _{DS(on)}	-	4.9 ¹⁾	100 ²⁾	mΩ	V _{GS} =10 V ,I _D =2.0 A
Reverse diode forward on-voltage	V _{SD}	-	1.0	1.2	V	V _{GS} =0 V ,I _F =1A
Internal gate resistance	R _G	-	2.3	-	Ω	-
Additional gate resistor	R _{Gadd}	13.6	17	20.4	Ω	-
Avalanche energy, single pulse	E AS	-	45 ³⁾	-	mJ	I_D =30 $A^{2)}$, R_{GS} =25 Ω

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 $^{^{1)}}$ typical bare die $R_{\rm DS(on)}$ $^{2)}$ limited by wafer test-equipment $^{3)}$ Wafer tested. For general avalanche capability refer to the datasheet of IPP075N15N3 G



3 Package Outlines

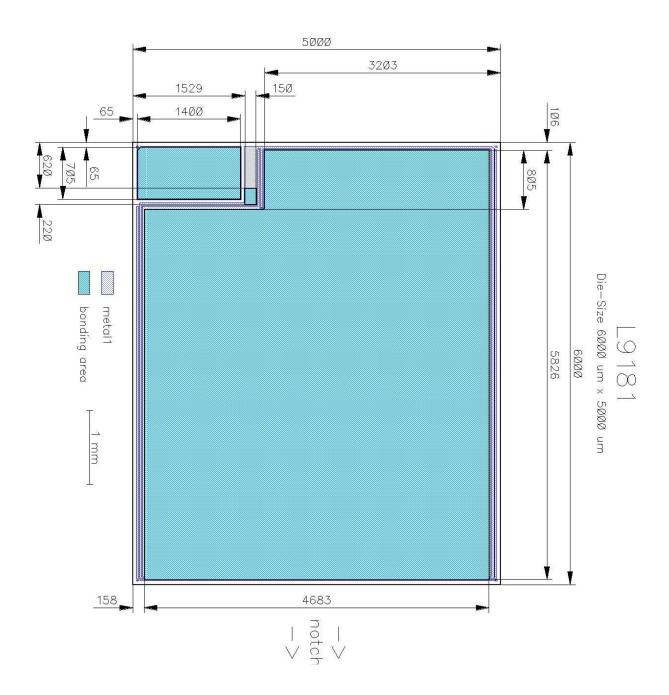


Figure 1 Outline Chip, dimensions in µm



OptiMOS™3 Power MOS Transistor Chip

IPC300N15N3R

Revision History

IPC300N15N3R

Revision: 2015-09-02, Rev. 2.6

Previous Revision

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Revision	Date	Subjects (major changes since last revision)		
2.5	2014-10-03	Release Final Version		
2.6	2015-09-02	Update layout picture		

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